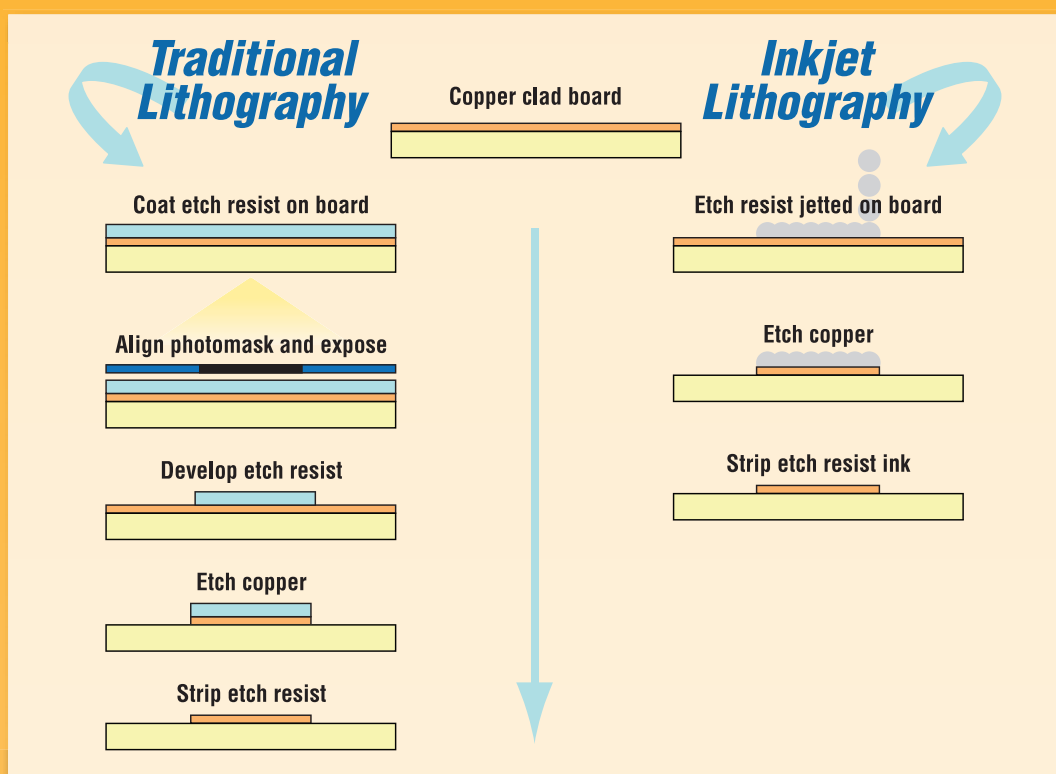


LithoJet™ 210 Etch Resist

Revolutionary Digital Fabrication Process

Description

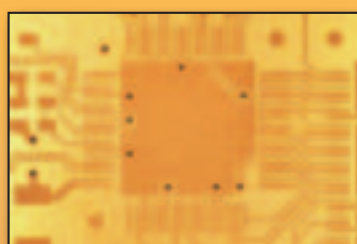
LithoJet 210 Etch Resist is a UV-curable acrylic hybrid ink that redefines the etching process for PWB inner layer fabrication. It is part of a simple 3-step digital process that can drastically improve yield and quality, as well as reduce manufacturing cost.



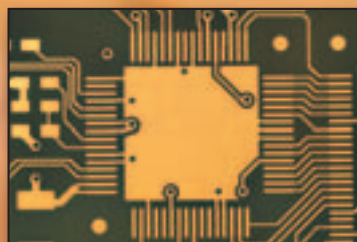
Benefits

- Eliminate dry film cost
- Reduced work in process
- Reduced waste in materials and energy
- Elimination of photo-masks
- Improved cycle time
- Higher yields

Cheaper
Faster
Better



Panel printed with
LithoJet 210 Etch Resist



Etched and stripped panel

[Click here for
more information](#)